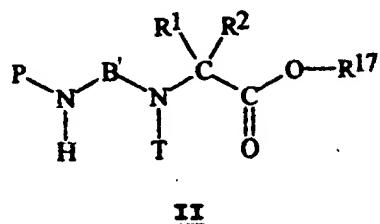
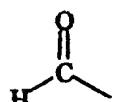


APPENDIX (with claim markings):

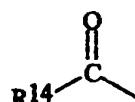
6. (Amended) A compound of the general formula II



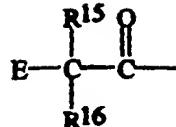
in which T is hydrogen or a group of the formula



or



or



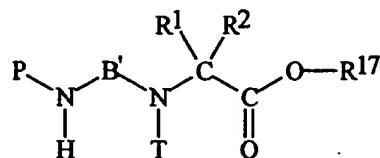
the residue R¹⁷ is hydrogen or allyl, benzyl, ethyl, methyl, 2,2,2-trichloro-tert-butyl, 2,2,2-trichloroethyl, α -chloro-(trifluoromethyl)benzyl, 2-(p-toluenesulfonyl)ethyl, diphenyl-methyl, 2-(trimethylsilyl)ethyl, methoxymethyl, (2-trimethyl-silyl)ethoxymethyl, benzyloxymethyl, or (2-methoxy) ethyloxymethyl,

the residue P is hydrogen or an amine protecting group,

the residue R¹⁴ is a group of the formula CH_nX_{3-n} (n = 0 to 3, X = F, Cl, Br, I), a phenyl group, or a p-methoxyphenyl group, and

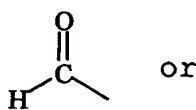
B', E, the residues R¹ [und] and R², and R¹⁵ [und] and R¹⁶ have the meanings stated in [claims 1 to 5] claim 1.

9. (Twice Amended) A process for the production of a compound as defined in claim 1, wherein compounds of the general formula II

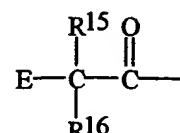


III

in which T is hydrogen or a group of the formula



$$\begin{array}{c} \text{O} \\ \parallel \\ \text{R}_{14}-\text{C}-\text{CH}_3 \end{array}$$



the residue R¹⁷ is hydrogen or allyl, benzyl, ethyl, methyl, 2,2,2-trichloro-tert-butyl, 2,2,2-trichloroethyl, α-chloro-(trifluoromethyl)benzyl, 2-(p-toluenesulfonyl)ethyl, diphenyl-methyl, 2-(trimethylsilyl)ethyl, methoxymethyl, (2-trimethyl-silyl)ethoxymethyl, benzyloxymethyl, or (2-methoxy)ethyloxymethyl.

the residue P is hydrogen or an amine protecting group.

the residue R¹⁴ is a group of the formula CH_nX_{3-n} (n = 0 to 3, X = F, Cl, Br, I), a phenyl group, or a p-methoxyphenyl group, and

B', E, the residue R¹ and R², and R¹⁵ and R¹⁶ have the meanings stated in claim 1 [wherein compounds as defined in claim 6] are converted in known matter.